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	Application No.	Applicant(s)
Notice of Allowability	10/706,178	NOSOWITZ ET AL.
	Examiner	Art Unit
	Gregory E. Webb	1751
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT F of the Office or upon petition by the applicant. See 37 CFR 1.31	6 (OR REMAINS) CLOSED in this a i) or other appropriate communication RIGHTS. This application is subject	pplication. If not included
1. This communication is responsive to <u>2/17/04</u> .		
2. The allowed claim(s) is/are <u>1-17</u> .		
3. The drawings filed on are accepted by the Examine	er.	
4. ☐ Acknowledgment is made of a claim for foreign priority u a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents have 2. ☐ Certified copies of the priority documents have 3. ☐ Copies of the certified copies of the priority do International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. ☐ A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give 6. ☐ CORRECTED DRAWINGS (as "replacement sheets") must (a) ☐ including changes required by the Notice of Draftspers	e been received. e been received in Application No becoments have been received in this of this communication to file a reply MENT of this application. witted. Note the attached EXAMINER es reason(s) why the oath or declarates to be submitted.	r national stage application from the complying with the requirements at AMENDMENT or NOTICE OF ation is deficient.
(a) ☐ including changes required by the Notice of Draftspers 1) ☐ hereto or 2) ☐ to Paper No./Mail Date	son's Patent Drawing Review (PTO-	-948) attached
(b) ☐ including changes required by the attached Examiner's Paper No./Mail Date		Office action of
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the	.84(c)) should be written on the drawing to 37 CFR 1.121(ngs in the front (not the back) of d).
7. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT I	sit of BIOLOGICAL MATERIAL r FOR THE DEPOSIT OF BIOLOGIC	must be submitted. Note the AL MATERIAL.
Attachment(s)		
1. Notice of References Cited (PTO-892)		atent Application (PTO-152)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	 Interview Summary Paper No./Mail Dat 	(PTO-413), e
 Information Disclosure Statements (PTO-1449 or PTO/SB/08 Paper No./Mail Date 021304 	8), 7. Examiner's Amend	nent/Comment
4. Examiner's Comment Regarding Requirement for Deposit	8. X Examiner's Stateme	nt of Reasons for Allowance
of Biological Material	9. Other	
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REASONS FOR ALLOWANCE

1. Claims 1-17 are allowed. The following is an examiner's statement of reasons for allowance:

- 2. The applicant's claims are directed to a slurry composition which contains a sulfur bearing compound capable of converting copper to copper sulfide (i.e. cupric sulfide).
- 3. Although the chemical reaction of copper to copper sulfide is well known in various other fields such as processing raw ore or etching aluminum, such reactions are not known for use in planarization using a slurry. A slurry is defined as "a thin water suspension." None of the prior art uses these copper sulfide reactants in such a thermodynamic state. In fact, the prior art makes efforts to avoid non-soluble compounds especially in etching.
- 4. The closest prior art was found to be Rooney (US 4,116,699), Kawaguchi (US 5,953,628), Komai et al (US 6,709,979).
- 5. Rooney teaches polishing compositions containing the cupric sulfide, but fails to teach the formation of this compound during chemical mechanical polishing and the slurry state.
- 6. Kawaguchi teaches the formation of copper sulfides using ammonium sulfide in the manufacturing of semiconductors. However, Kawaguchi fails to teach these compositions in the form of a slurry.
- 7. Komai teaches an electrolytic plating composition containing copper sulfide. Komai however fails to teach the formation of the copper sulfide or the use of this compound in a slurry.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue

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fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Gregory E. Webb whose telephone number is 571-272-1325. The examiner can normally be reached on 9:00-17:30 (m-f).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Yogendra Gupta can be reached on 571-272-1316. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Gregory E. Webb Primary Examiner Art Unit 1751

gw